

## SEARCH REQUEST FORM

Scientific and Technical Information Center

Requester's Full Name: Sin J. Lee Examiner #: 76060 Date: 8-29-03  
 Art Unit: 1752 Phone Number 305-0504 Serial Number: 10/003,288  
 Mail Box and Bldg/Room Location: 9805 Results Format Preferred (circle): PAPER DISK E-MAIL

If more than one search is submitted, please prioritize searches in order of need.

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Please provide a detailed statement of the search topic, and describe as specifically as possible the subject matter to be searched. Include the elected species or structures, keywords, synonyms, acronyms, and registry numbers, and combine with the concept or utility of the invention. Define any terms that may have a special meaning. Give examples or relevant citations, authors, etc, if known. Please attach a copy of the cover sheet, pertinent claims, and abstract.

Title of Invention: Amine Compounds, resist Compositions and Pattern  
 Inventors (please provide full names): Hatakeyama, Jun; Kobayashi, Tomohiro; Process  
Watanabe, Takeru

Earliest Priority Filing Date: 12-6-2001

\*For Sequence Searches Only\* Please include all pertinent information (parent, child, divisional, or issued patent numbers) along with the appropriate serial number.

Amine Compound of the formula (3) of Cl. #1  
 (preferably, the compound is used in a resist  
 or photoresist composition. But please don't  
 limit the search to that unless there are  
 too many hits).

Thanks!

## STAFF USE ONLY

## Type of Search

## Vendors and cost where applicable

Searcher: EL NA Sequence (#) \_\_\_\_\_ STN \$  
 Searcher Phone #: \_\_\_\_\_ AA Sequence (#) \_\_\_\_\_ Dialog \_\_\_\_\_  
 Searcher Location: \_\_\_\_\_ Structure (#) 1 Questel/Orbit \_\_\_\_\_  
 Date Searcher Picked Up: \_\_\_\_\_ Bibliographic and Pr. Link \_\_\_\_\_  
 Date Completed: 8-29-03 Litigation \_\_\_\_\_ Lexis/Nexis \_\_\_\_\_  
 Searcher Prep & Review Time: 5 Fulltext \_\_\_\_\_ Sequence Systems \_\_\_\_\_  
 Clerical Prep Time: \_\_\_\_\_ Patent Family \_\_\_\_\_ WWW/Internet \_\_\_\_\_  
 Online Time: 30 Other \_\_\_\_\_ Other (specify) \_\_\_\_\_

# SEARCH REQUEST FORM

Scientific and Technical Information Center

Requester's Full Name: Sin J. Lee Examiner #: 76060 Date: 8-27-03  
Art Unit: 1752 Phone Number 30 5-6504 Serial Number: 10/003,288  
Mail Box and Bldg/Room Location: 9875 Results Format Preferred (circle): PAPER DISK E-MAIL

If more than one search is submitted, please prioritize searches in order of need.  
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Please provide a detailed statement of the search topic, and describe as specifically as possible the subject matter to be searched. Include the elected species or structures, keywords, synonyms, acronyms, and registry numbers, and combine with the concept or utility of the invention. Define any terms that may have a special meaning. Give examples or relevant citations, authors, etc, if known. Please attach a copy of the cover sheet, pertinent claims, and abstract.

Title of Invention: Amine Compounds, resist compositions and pattern  
Inventors (please provide full names): Hatakeyama, Jun; Kobayashi, Tomohiro; Prosen  
Watanabe, Takeru  
Earliest Priority Filing Date: 12-6-2001

\*For Sequence Searches Only\* Please include all pertinent information (parent, child, divisional, or issued patent numbers) along with the appropriate serial number.

Amine compound of the formula (4) of Cl. # 1.  
(preferably, the compound is used in a  
resist or photoresist composition).  
But please don't limit the search to  
that unless there are too many hits).  
Thanks !

STAFF USE ONLY		Type of Search	Vendors and cost where applicable
Searcher: <u>EE</u>	NA Sequence (#) _____	STN _____	
Searcher Phone #: _____	AA Sequence (#) _____	Dialog _____	
Searcher Location: _____	Structure (#) <u>(1)</u>	Questel/Orbit _____	
Date Searcher Picked Up: _____	Bibliographic <u>(1)</u>	Dialog Link _____	
Date Completed: <u>8-29-03</u>	Litigation <u>(1)</u>	Lexis/Nexis _____	
Searcher Prep & Review Time: <u>5</u>	Fulltext _____	Sequence Systems _____	
Clerical Prep Time: _____	Patent Family _____	WWW/Internet _____	
Online Time: <u>30</u>	Other _____	Other (specify) _____	

**SEARCH REQUEST FORM**

Scientific and Technical Information Center

Requester's Full Name: Sin J. Lee Examiner #: 76060 Date: 8-27-03  
 Art Unit: 1752 Phone Number 30 5-0504 Serial Number: 10/003,288  
 Mail Box and Bldg/Room Location: 9B45 Results Format Preferred (circle): PAPER DISK E-MAIL

If more than one search is submitted, please prioritize searches in order of need.

\*\*\*\*\*  
 Please provide a detailed statement of the search topic, and describe as specifically as possible the subject matter to be searched. Include the elected species or structures, keywords, synonyms, acronyms, and registry numbers, and combine with the concept or utility of the invention. Define any terms that may have a special meaning. Give examples or relevant citations, authors, etc, if known. Please attach a copy of the cover sheet, pertinent claims, and abstract:

Title of Invention: Amine Compounds, resist Compositions & Pattern

Inventors (please provide full names): Hatakeyama, Jun; Proas

Kabayashi, Tomohiro; Watanabe, Takeru

Earliest Priority Filing Date: 12-6-2001

\*For Sequence Searches Only\* Please include all pertinent information (parent, child, divisional, or issued patent numbers) along with the appropriate serial number.

Amine compound of the formula (I) of

Claim #1 (preferably, the compound is used in a resist (or photoresist) composition. but please don't limit the search to that unless there are too many hits).

Thanks!

**STAFF USE ONLY**

Searcher: <u>Kan Rm</u>	Type of Search	Vendors and cost where applicable
Searcher Phone #: <u>305 3542</u>	NA/Sequence (#) _____	STN <input checked="" type="checkbox"/>
Searcher Location: <u>ESC 1703</u>	AA Sequence (#) _____	Dialog _____
Date Searcher Picked Up: <u>9/12/03</u>	Structure (#) <input checked="" type="checkbox"/>	Questel/Orbit _____
Date Completed: <u>9/13/03</u>	Bibliographic _____	Dr.Link _____
Searcher Prep & Review Time: <u>60 min</u>	Litigation _____	Lexis/Nexis _____
Clerical Prep Time: _____	Fulltext _____	Sequence Systems _____
Online Time: <u>120 min</u>	Patent Family _____	WWW/Internet _____
	Other _____	Other (specify) _____